IN THE CLAIMS:

Please amend claims 1, 8, 13 and 18 and please add the following new claims as shown below:

1. (currently amended) A process for manufacturing a liquid crystal display device including a step of irradiating polarized UV light to an orientation film formed on a substrate <u>having at least a portion of a common electrode and a pixel</u> <u>electrode formed of a same material and provided on the substrate</u> while heating the substrate, wherein the heating is provided by a stage associated with the substrate which moves the substrate while the orientation film formed on the substrate is irradiated.

Claims 2 and 3 (canceled)

- 4. (original) A process for manufacturing a liquid crystal display device according to claim 1, wherein the UV light is provided by a light source which is at least one of an excimer laser, argon laser, gas laser, solid-state laser, semiconductor laser and pigment laser.
- 5. (original) A process for manufacturing a liquid crystal display device according to claim 1, wherein the UV light is provided by a light source which is at least one of a high-pressure, middle-pressure and low-pressure mercury arc lamp and a xenon lamp.
- 6. (original) A process for manufacturing a liquid crystal display device according to claim 1, wherein the liquid crystal display device is a lateral electric field type liquid crystal display device.

- 7. (original) A process for manufacturing a liquid crystal display device according to claim 1, wherein orientation easy axes of an upper orientation film formed on an upper substrate and a lower orientation film formed on a lower substrate are substantially parallel to one another.
- 8. (currently amended) A process for manufacturing a liquid crystal display device including a step of irradiating polarized UV light to an orientation film formed on a substrate <u>having at least a portion of a common electrode and a pixel electrode formed of a same material and provided on the substrate while maintaining a temperature of the substrate higher than room temperature, wherein the temperature of the substrate is maintained by a stage associated with the substrate which heats and moves the substrate while the orientation film formed on the substrate is irradiated.</u>
- 9. (original) A process for manufacturing a liquid crystal display device according to claim 8, wherein the UV light is provided by a light source which is at least one of an excimer laser, argon laser, gas laser, solid-state laser, semiconductor laser and pigment laser.
- 10. (original) A process for manufacturing a liquid crystal display device according to claim 8, wherein the UV light is provided by a light source which is at least one of a high-pressure, middle-pressure and low-pressure mercury arc lamp and a xenon lamp.
- 11. (original) A process for manufacturing a liquid crystal display device according to claim 8, wherein the liquid crystal display device is a lateral electric field type liquid crystal display device.

- 12. (original) A process for manufacturing a liquid crystal display device according to claim 8, wherein orientation easy axes of an upper orientation film formed on an upper substrate and a lower orientation film formed on a lower substrate are substantially parallel to one another.
- display device including a step of irradiating polarized UV light to an orientation film formed on a substrate <u>having at least a portion of a common electrode and a pixel</u> <u>electrode formed of a same material and provided on the substrate</u> for a time period while maintaining a temperature of the substrate which is higher than room temperature, the time period being less than a time period when the substrate is not maintained at the higher temperature, wherein the temperature of the substrate is maintained by a stage associated with the substrate which heats and moves the substrate while the orientation film formed on the substrate is irradiated.
- 14. (original) A process for manufacturing a liquid crystal display device according to claim 13, wherein the UV light is provided by a light source which is at least one of an excimer laser, argon laser, gas laser, solid-state laser, semiconductor laser and pigment laser.
- 15. (original) A process for manufacturing a liquid crystal display device according to claim 13, wherein the UV light is provided by a light source which is at least one of a high-pressure, middle-pressure and low-pressure mercury arc lamp and a xenon lamp.
- 16. (original) A process for manufacturing a liquid crystal display device according to claim 13, wherein said liquid crystal display device is a lateral electric field type liquid crystal display device.

- 17. (original) A process for manufacturing a liquid crystal display device according to claim 13, wherein orientation easy axes of an upper orientation film formed on an upper substrate and a lower orientation film formed on a lower substrate are substantially parallel to one another.
- 18. (currently amended) A liquid crystal display device including orientation film formed on a substrate <u>having at least a portion of a common electrode and a pixel electrode formed of a same material and provided on the substrate</u>, wherein the orientation film is irradiated by polarized UV light while heating of the substrate for orientation of the orientation film, wherein the heating is provided by a stage associated with the substrate which moves the substrate while the orientation film formed on the substrate is irradiated.
- 19. (original) A liquid crystal display device according to claim 18, wherein the liquid crystal display device is a lateral electric filed type liquid crystal display device.
- 20. (original) A liquid crystal display device according to claim 18, wherein the liquid crystal display device has a size of at least 10 inches.

Claims 21-24 (canceled)

- 25. (new) A process for manufacturing a liquid crystal display device according to claim 1, wherein the same material is ITO.
- 26. (new) A process for manufacturing a liquid crystal display device according to claim 8, wherein the same material is ITO.

- 27. (new) A process for manufacturing a liquid crystal display device according to claim 13, wherein the same material is ITO.
- 28. (new) A liquid crystal display device according to claim 18, wherein the same material is ITO.
- 29. (new) A liquid crystal display device including orientation film formed on a substrate having at least a portion of a common electrode and a pixel electrode formed of a same material and provided on the substrate, wherein the orientation film is irradiated by polarized UV light.
- 30. (new) A liquid crystal display device including orientation film formed on a substrate having at least a portion of a common electrode and a pixel electrode formed of a same material and provided on the substrate, wherein the orientation film is irradiated by polarized UV light while heating a substrate for orientation of the orientation film, wherein the heating is provided by a stage associated with the substrate.